**Broadband emission in Er-Tm codoped ZnO film: Energy transfer from ZnO host to rare earth ions** Z. R. Dong<sup>1</sup>, F. Xu<sup>2\*</sup>, Z. M. Jiang<sup>1\*</sup> State Key Laboratory of Surface Physics, Department of Physics, Fudan University, Shanghai 200433, China <sup>2</sup>SHU-SolarE R&D Lab, Department of Physics, Shanghai Key Laboratory of High Temperature

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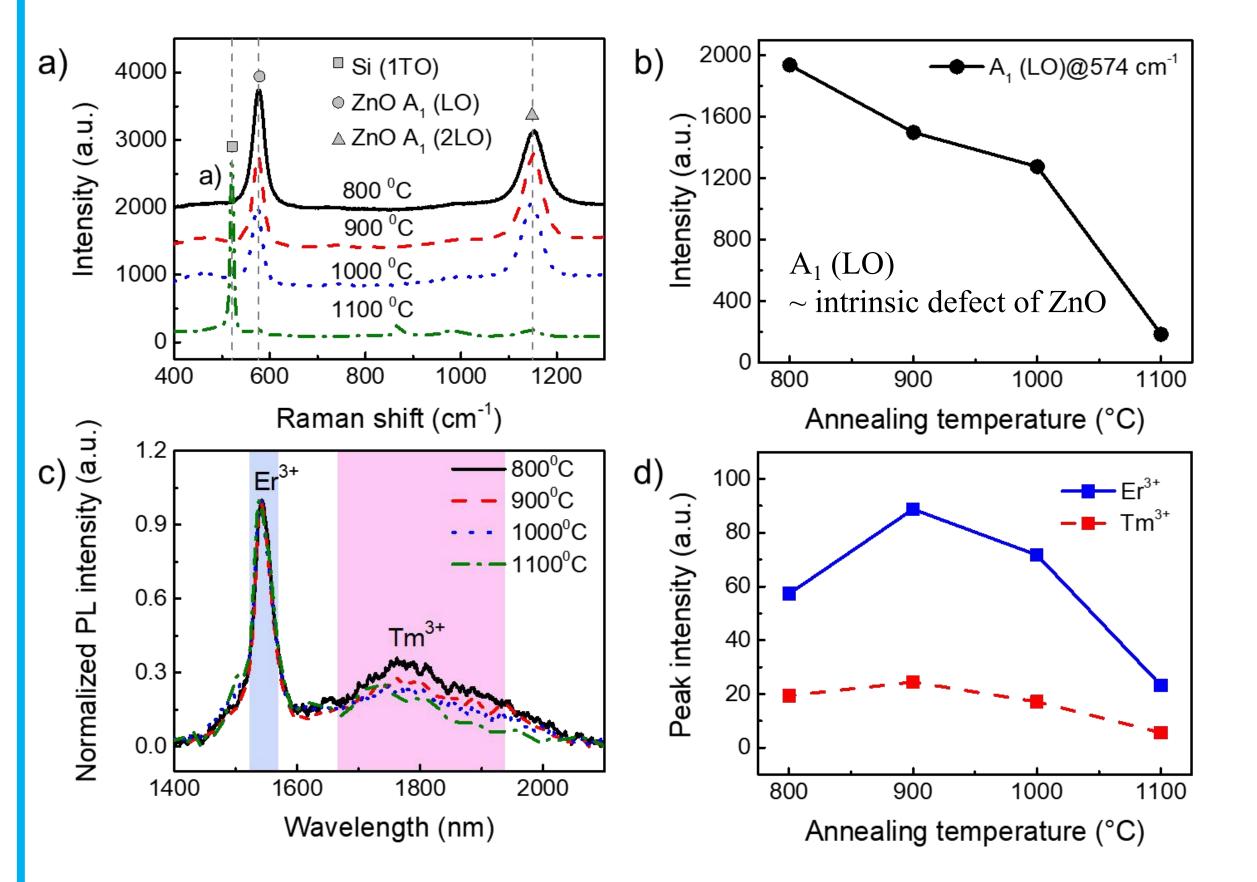
## Motivation

- The increasing demand for information traffic requires the development of the wide band  $_{0.8}$ light sources and optical amplifiers urgently for full utilization of the 1400-1700 nm lowloss window band of silicon-based optical fibers.
- Overlapping emission bands from different rare earth (RE) ions can be used to provide a route to achieve such broadband emission. (Er: 1540 nm, Tm: 1400-1500, 1600-2100 nm)



Er<sup>3+</sup>, Tm<sup>3+</sup>

## Photoluminescence (PL)



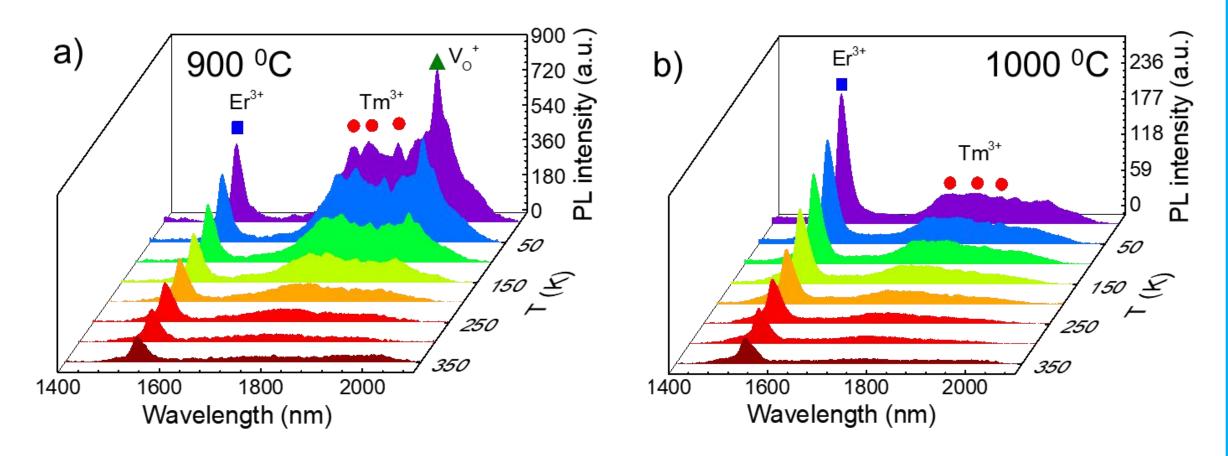


Figure 2 PL spectra of the ETZO films annealed at 900 a) and 1000 °C b) measured at different temperatures in the range of 10-350 K.

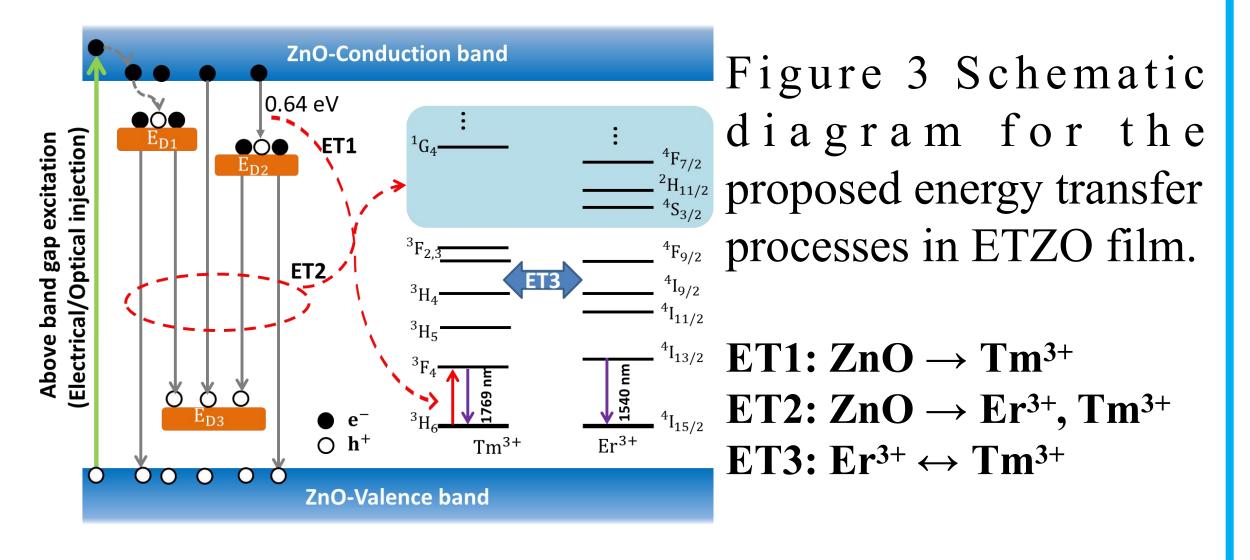


Figure 1 a) Raman spectra of the ETZO films. b) Annealing temperature dependence of the intensity of Raman peak at 574 cm<sup>-1</sup>. c) RT PL spectra of the ETZO films each is normalized by the corresponding emission intensity of Er<sup>3+</sup>. d) Annealing temperature dependencies of the intensity of the Er<sup>3+</sup> and Tm<sup>3+</sup> ions related emissions.

## Electroluminescence (EL)

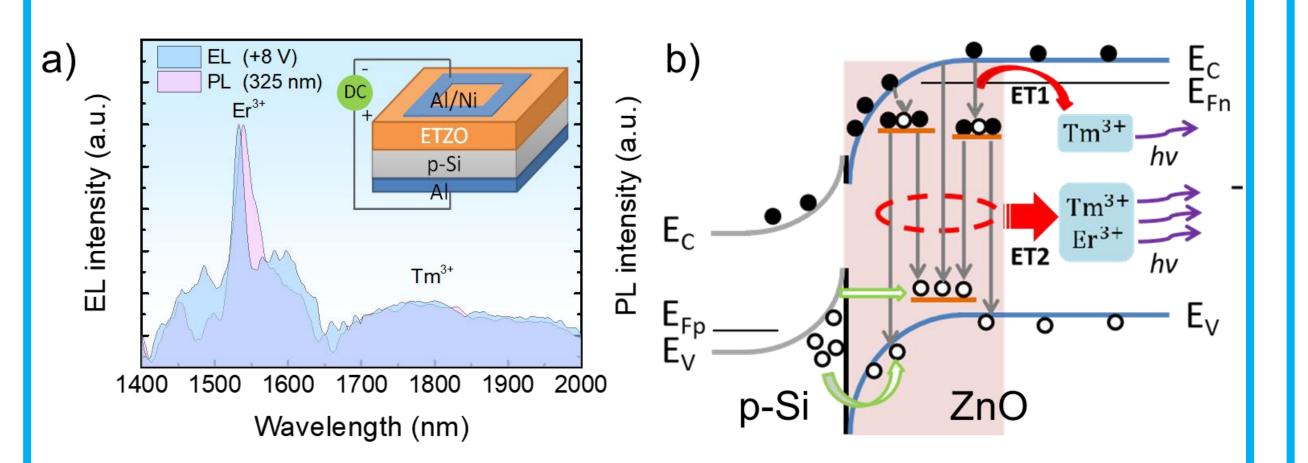


Figure 4 a) RT EL and PL spectra of Al/Ni/ETZO/p-Si/Al device. b) Schematic diagram for the energy band structure of the ETZO/p-Si device under sufficiently high forward

## Conclusion

- 1400-2100 nm broadband emission (PL and EL), attributed to the radiative transitions of  $Er^{3+}$ :  ${}^{4}I_{13/2}$  $\rightarrow$  <sup>4</sup>I<sub>15/2</sub> and Tm<sup>3+</sup>: <sup>3</sup>F<sub>4</sub>  $\rightarrow$  <sup>3</sup>H<sub>6</sub> was successfully achieved.
- The defect states of ZnO act as channels for the energy transfer from ZnO to Er<sup>3+</sup> and Tm<sup>3+</sup> ions by the recombination of the defect states.
- These results pave the way for the practical application of ETZO films as the broadband infrared optical amplifiers and light emitters.

